

表面・界面化学反応、磁性薄膜研究の ERLにおける将来展望

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Short pulse (0.1-1 ps), High rep rate (1.3 GHz; 0.8 ns)

Outline

- 時間分解実験
 - 表面反応の高速追跡
 - 分子吸着による表面磁性の変化の追跡
 - 磁化反転過程の観測、スピントロニクス材料を見据えて
 - 透過型軟X線顕微鏡
 - 磁気小角散乱
- ちょっと提案
 - 軟X線と硬X線が同時に使えるBL

What are prospective triggers?

- For surface chemical reaction
 - Pulsed valve: *Widely used now, but...*
 - Laser:
 - Photo-stimulated desorption (PSD)
 - Sudden heating
- For magnetization process
 - Pulsed current
 - Pulsed magnetic field



Pulse lengths down to 10 μs

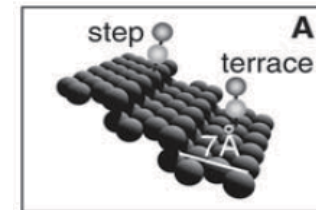


What are required time resolutions like?

< Laser-excited thermally non-equilibrium state, and ... >

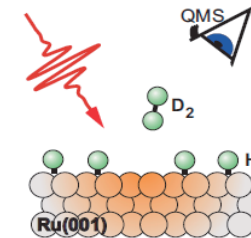
- Laser-induced Movement of CO on Pt: ~ 1 ps

– E. H. J. Backus, *et al.*, Science **310**, 1790 (2005).



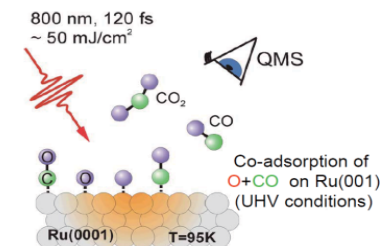
- Laser-induced desorption of D₂, D on Ru(0001): ~ 1 ps

– D. N. Denzler, *et al.*, PRL **91**, 226102 (2003).



- Laser-induced CO oxidation on Ru(0001): ~ 3 ps

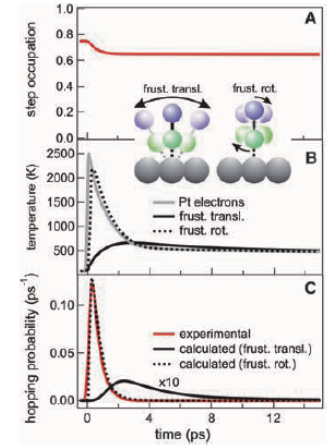
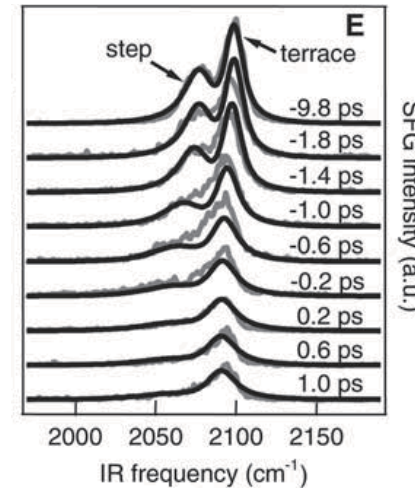
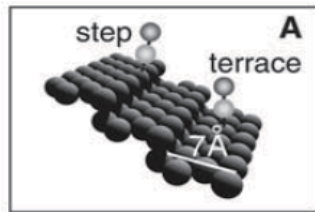
– M. Bonn, *et al.*, Science **285**, 1042 (1999).



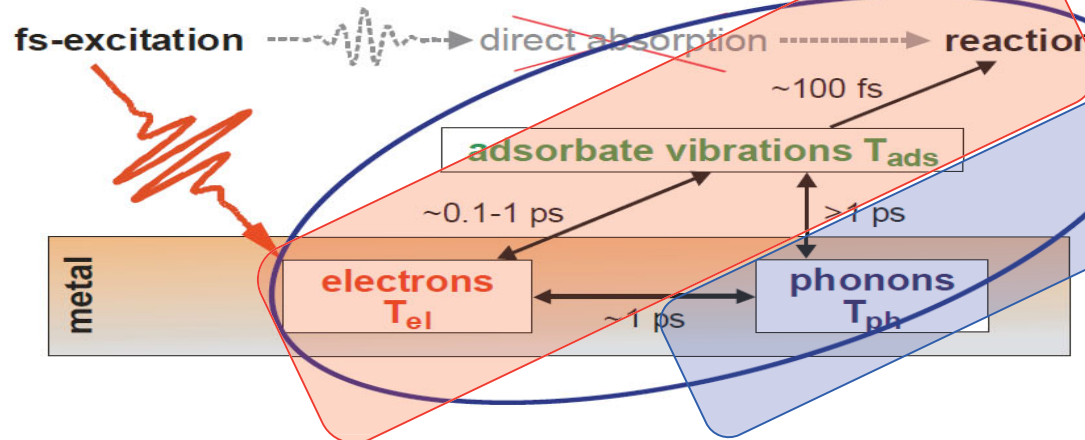
What are required time resolutions like?

< Laser-excited thermally non-equilibrium state, and ... >

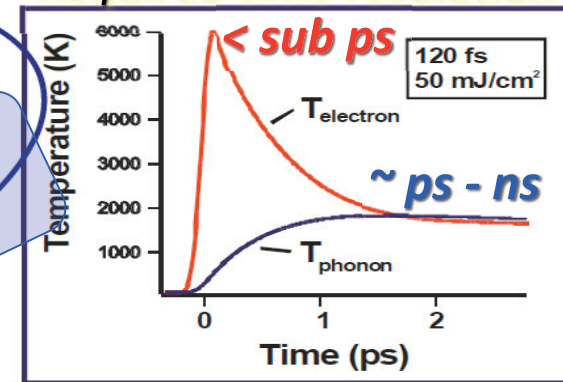
- Laser-induced Movement of CO on Pt: ~ 1 ps
 - E. H. J. Backus, *et al.*, Science **310**, 1790 (2005).



Mechanism and timescales of energy transfer after optical excitation



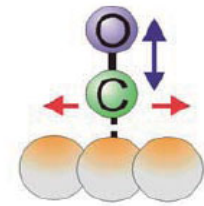
Required time resolution



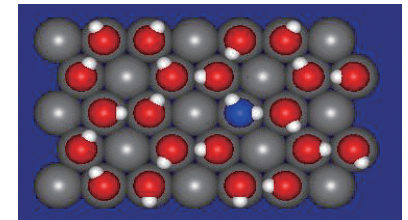
Anisimov, et al. Sov. Phys. JETP **39**, 375 (1974)

Time scales of thermally equilibrium phenomena

- CO site hopping on Ni(111) at 600 K: 210 ns
– Y. R. Shen, *et al.*, PRL **61**, 2883 (1988).



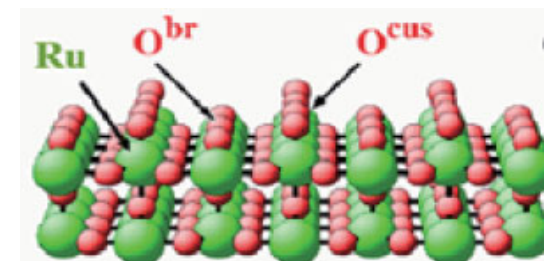
- Proton transfer on Pt(111) at 150 K: 5-50 ns
– M. Nagasaka, *et al.*, PRL **100**, 10610 (2008).



- CO desorption on RuO₂(110) at 600 K: 90 ns

- CO oxidation: 130 μs

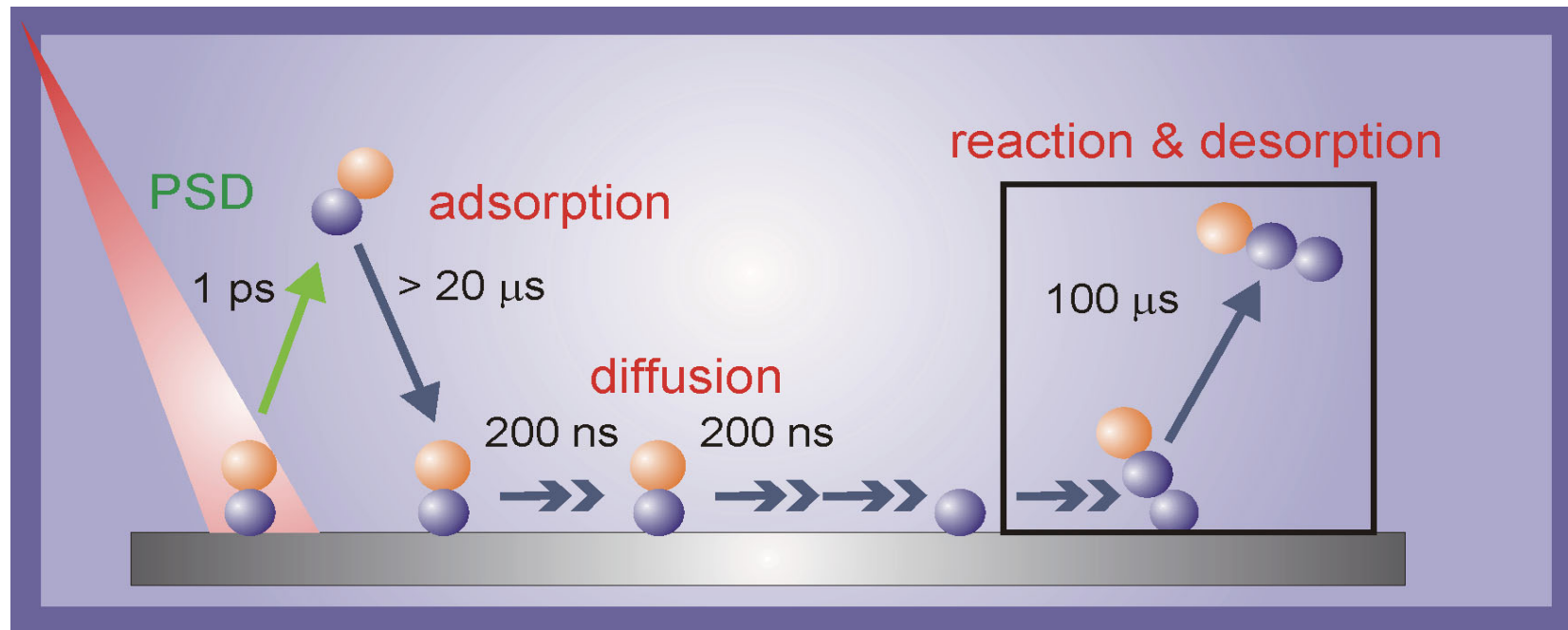
– K. Reuter, *et al.*, PRL **93**, 116105 (2004).



~ns snapshots:

Effective and just right to make “real time movies”

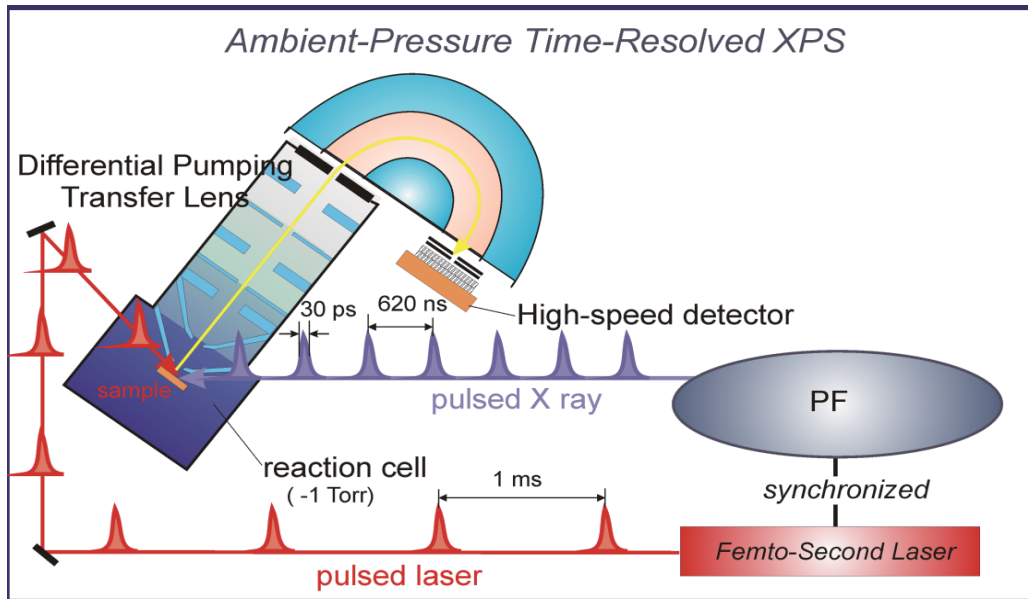
Time-resolved “pictures” of surface reaction



Laser pump – x-ray probe
(Snapshots with delay line)

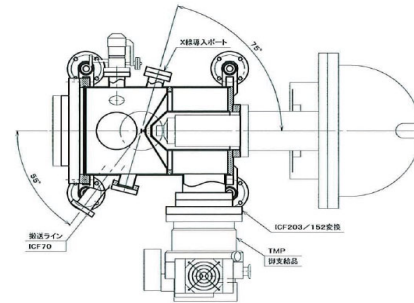
X-ray real time “movie”
(Successive pictures)

Ambient Pressure Time-Resolved XPS

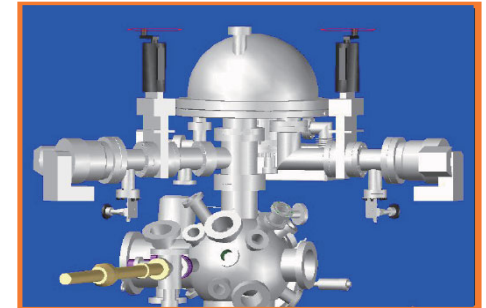


PF => ERL

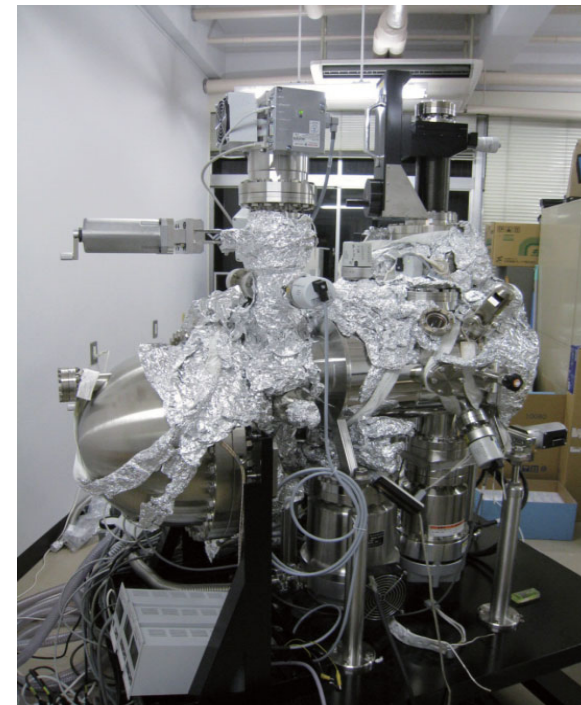
- Laser pump – x-ray probe
- Time-resolved inner shell spectroscopy
 - Time resolution: 30 ps => **< 1 ps**
 - Sampling rate: 620 ns/spec => **0.8 ns/spec**
- Pressure controllable
 - UHV - ~1 Torr



Diff. pumped Exp. chamber

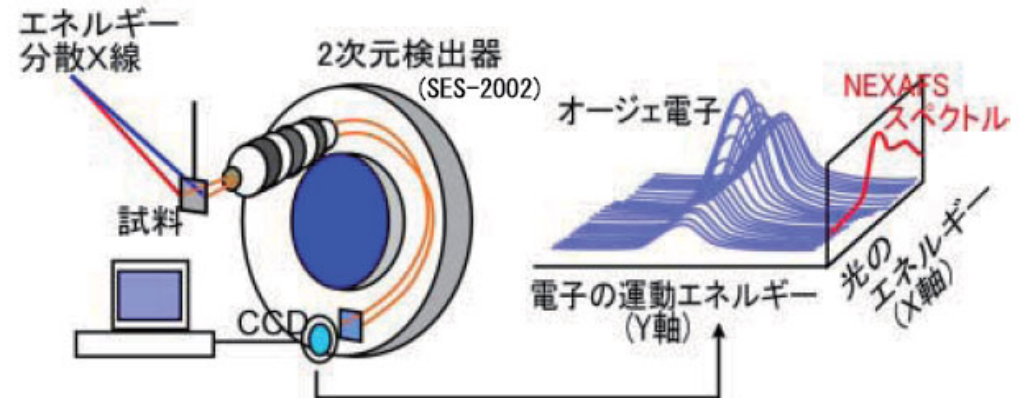
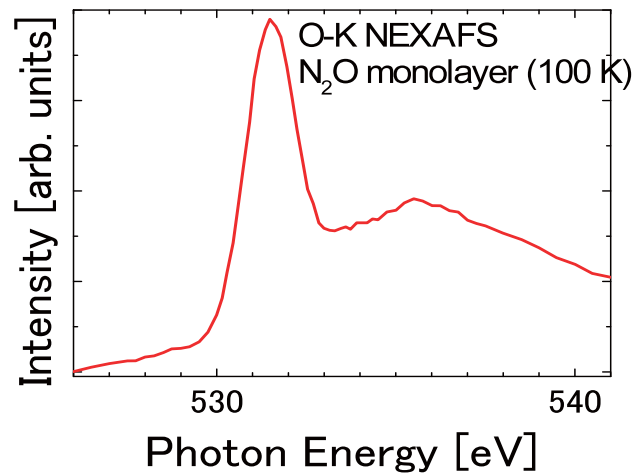


Diff. pumped e⁻ energy analyzer



Current status of our time-resolved experiment

Disp-NEXAFS



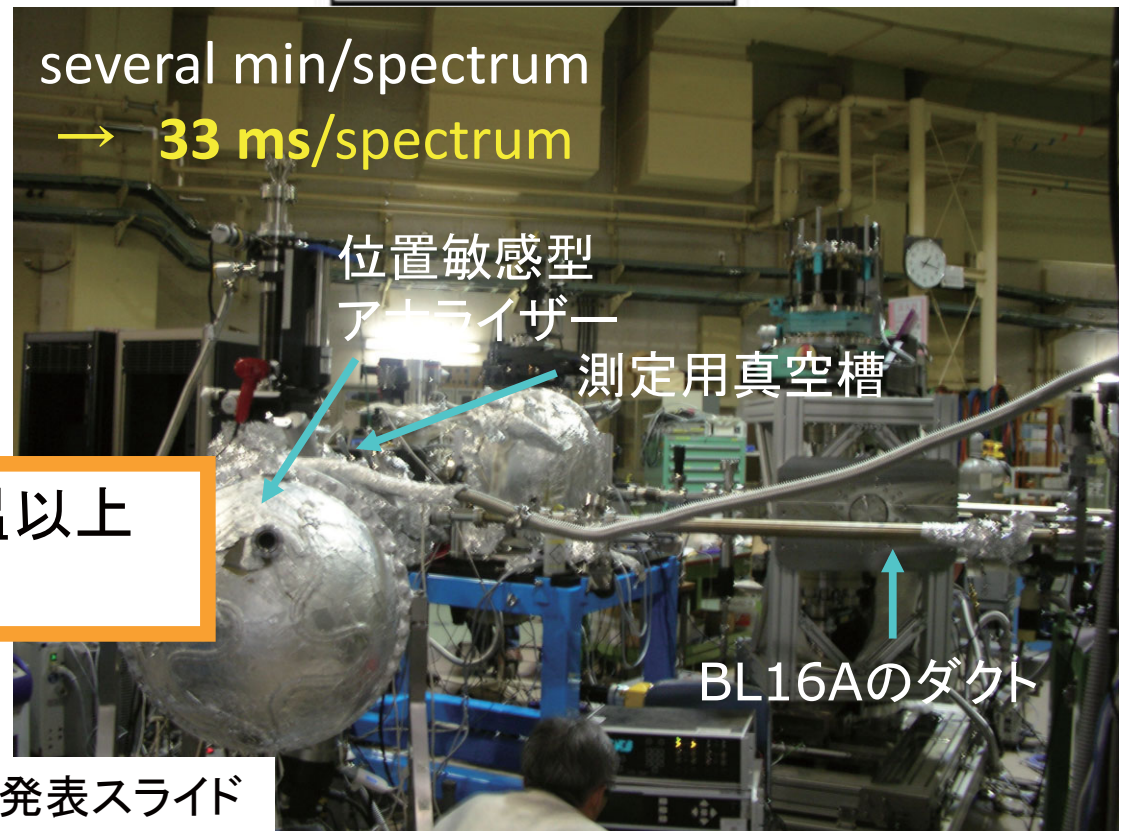
several min/spectrum
→ **33 ms/spectrum**

→ 反応が速い室温以上でも
追跡可能に！

[*]

Dispersive NEXAFS法を用いて室温以上
での反応を表面分光法で調べる

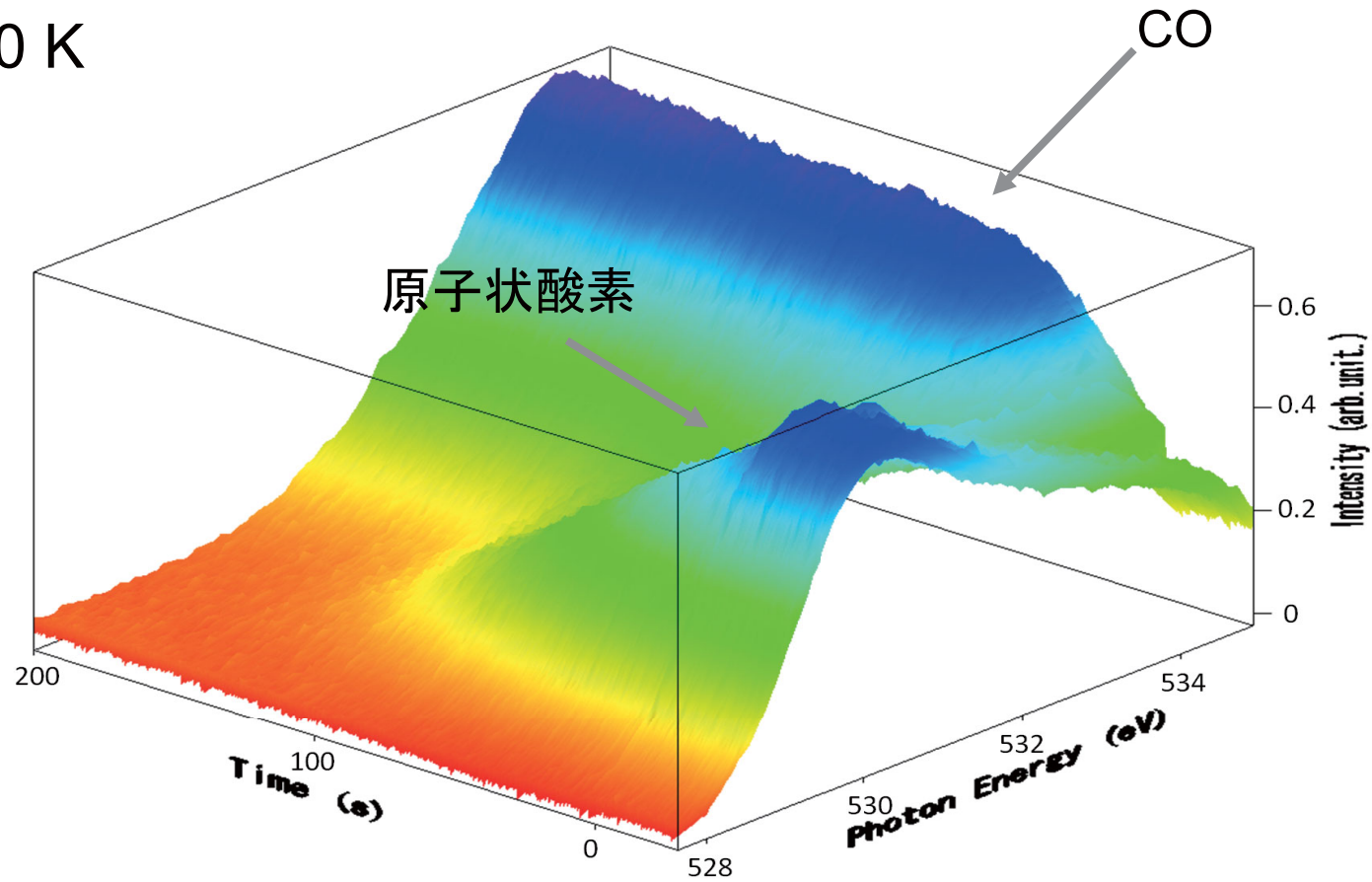
[*] 小宇佐友香 (慶應大、近藤研), 修士論文発表スライド



3Dプロット

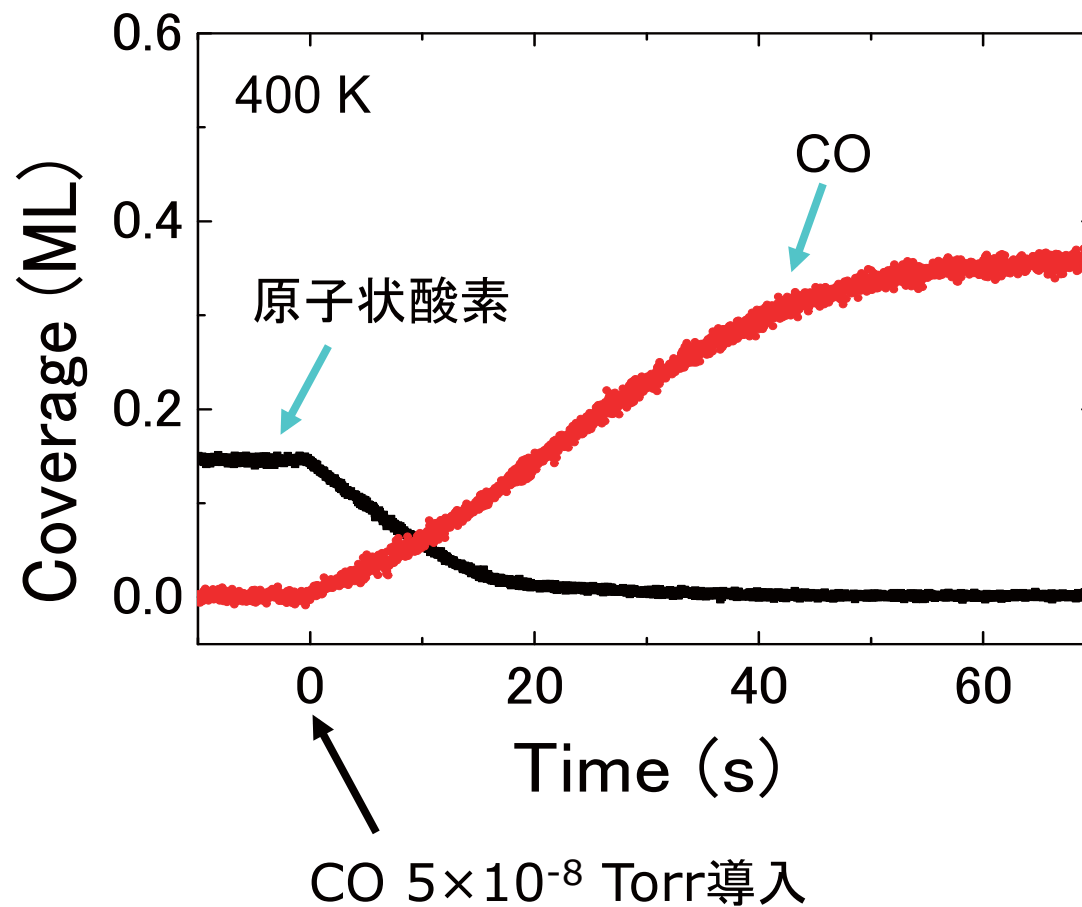
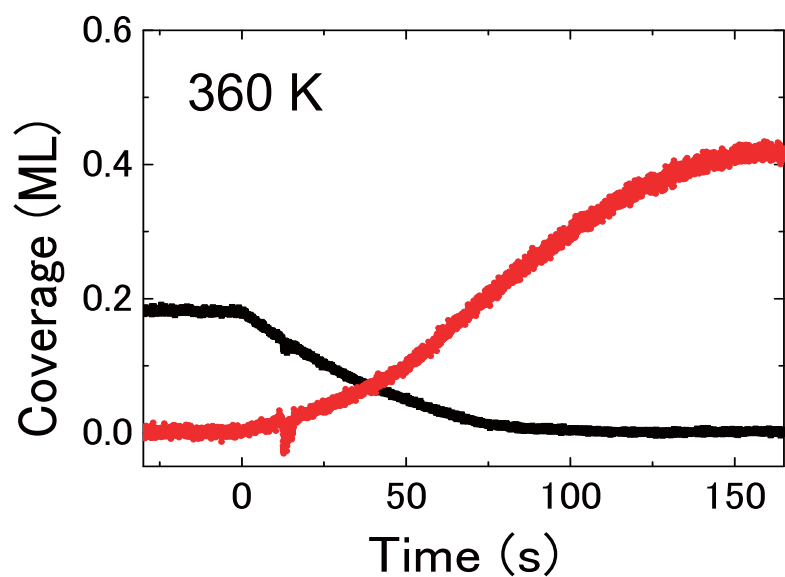
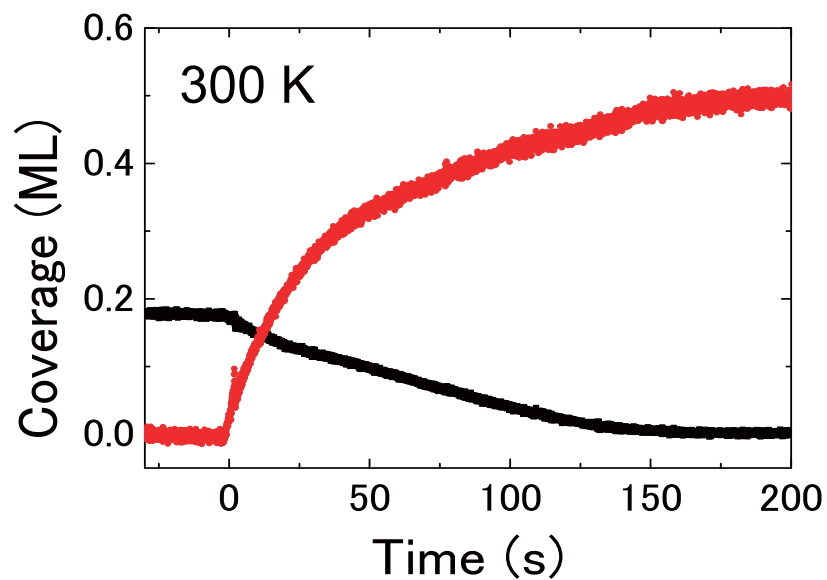
測定したO-K吸収端NEXAFSスペクトルを時間で並べたもの

300 K



* 小宇佐友香(慶應大、近藤研), 修士論文発表スライド

被覆率の時間変化



* 小宇佐友香(慶應大、近藤研), 修士論文発表スライド

Available time resolution & possible study

	Acquisition Rep rate	Period of real time observable reaction	Ratio (Period/Rep rate)
Current status: 16A at PF	33 ms (Video rate of the camera)	~100 s	$\sim 10^{3-4}$
Future: ERL	0.8 ns (Pulse interval)	(~100 ns)- 1 -10 μs	$\sim 10^{3-4}$

Real time observations of catalysts at very working temperature

For example...

How suitable!! Perfect!!

CO oxidation on Pt(111)

$$E_a = 0.5 - 0.7 \text{ eV}$$

RT => 600 - 900 K

(Ratio of k) = $10^4 - 10^8$

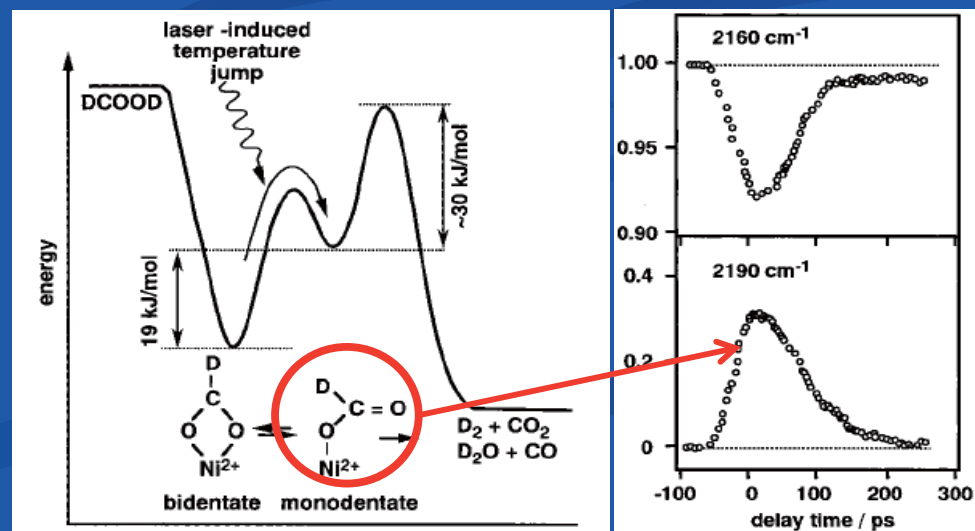
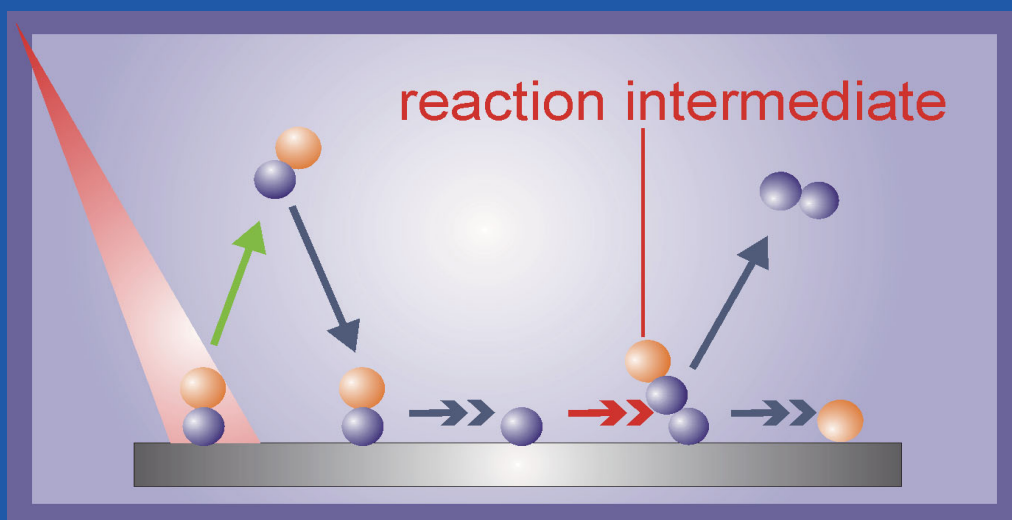
...maybe (^^;)

ERL光源による超高速反応モニタリング

- 100 fs ~ 1 psのパルス幅
- 1.3 GHz (0.8 ns間隔)のパルス列

100 fs ~ 1 psの時間分解能 → 短寿命反応中間体を捉えられる？

0.8 ns間隔でサンプリング → それが何時生成するかを調べられる

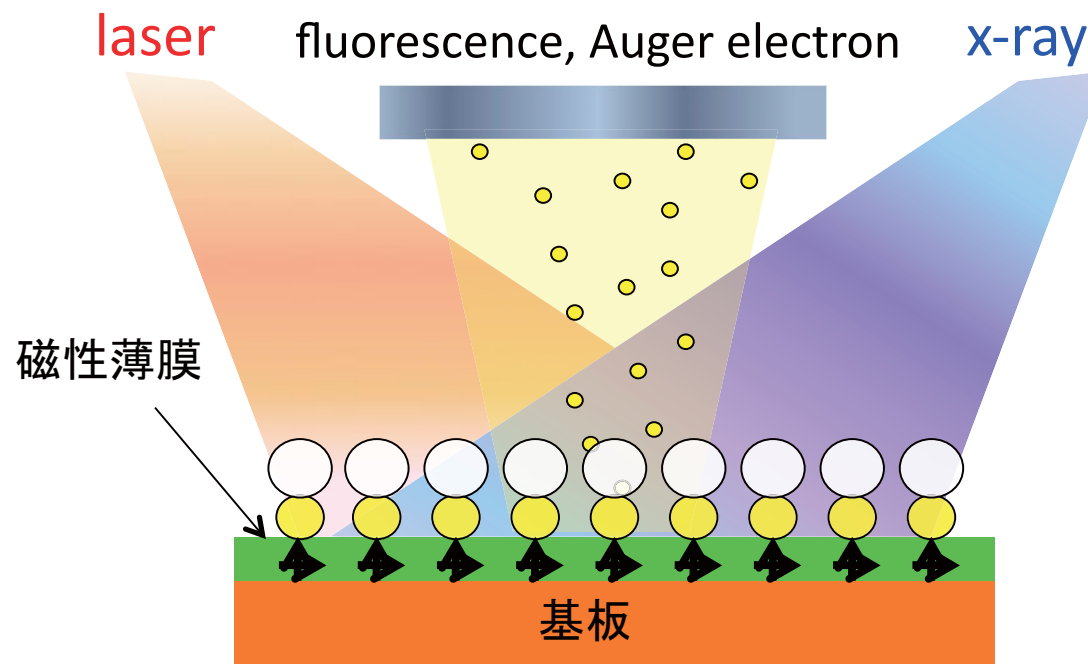
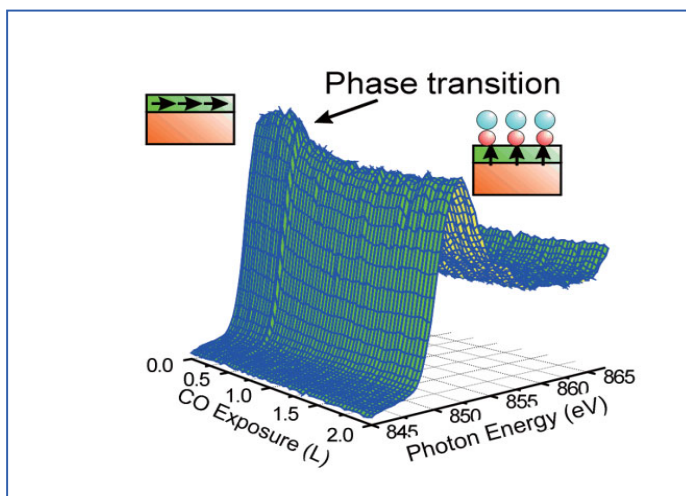


A. Bandara et al. *J. Phys. Chem. B* 102, 5951 (1998).

磁性薄膜での雰囲気制御時間分解測定

分子吸着誘起スピン再配列転移(SRT)

雰囲気制御時間分解XMCD, EXAFS



PSDによる磁性薄膜表面からの分子の脱離

分子脱離による SRT
ps-ns
薄膜構造の変化

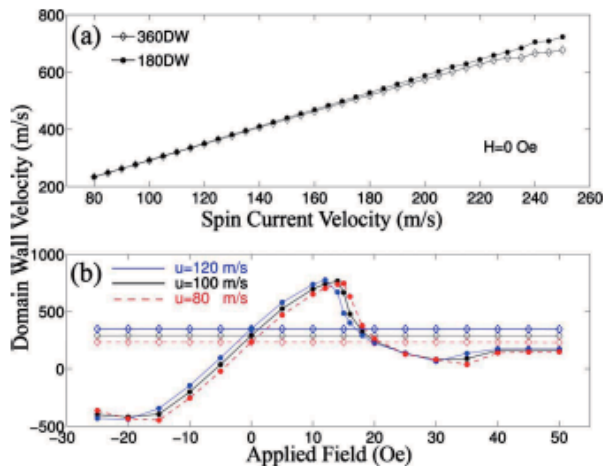
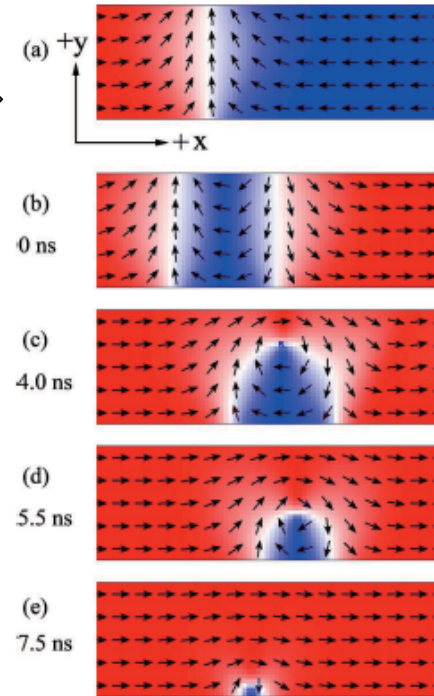
分子再吸着による
薄膜構造の再変化
元の状態へのSRT

Observation of Magnetic Reversal Process

Magnetic reversal process
Domain wall (DW) movement

typical period: ~ns

Velocity { several m/s [強磁性体の物理]
~10⁻³ m/s [Science, PRB]



ERL光 パルス幅1 ps
パルス間隔 0.8 ns

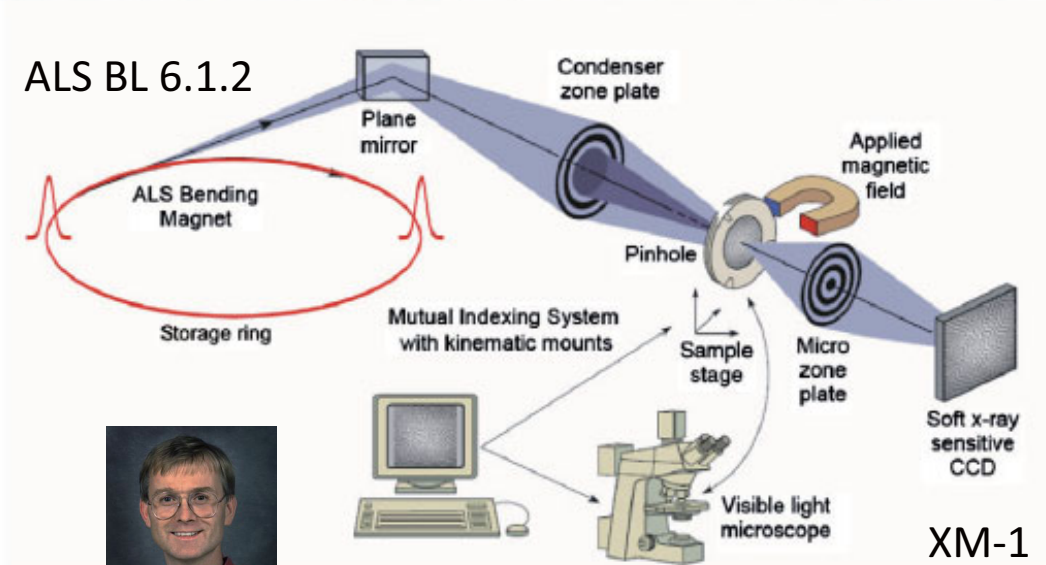
工夫も必要だが

ERLを用いた実験に適した現象ではないか

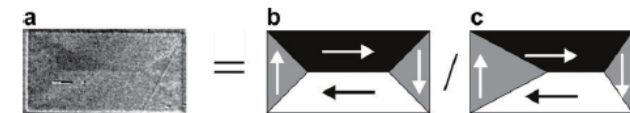
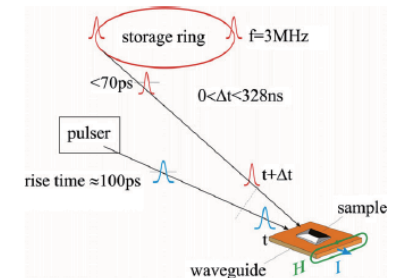
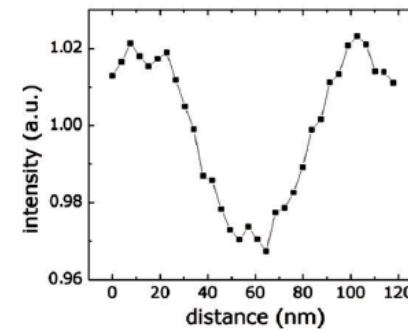
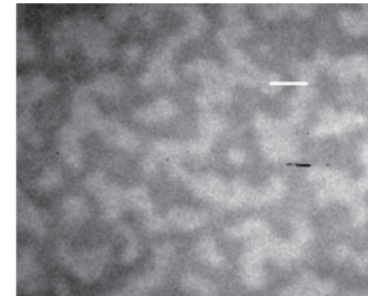
Magnetic transmission soft x-ray microscopy
(磁気透過型軟X線顕微鏡)
Magnetic soft x-ray small angle scattering
(磁気軟X線小角散乱)

Magnetic transmission soft X-ray microscopy

(磁氣)透過型軟X線顯微鏡



P. Fischer, *et al.*, Surf. Sci. **601**, 4680 (2007)

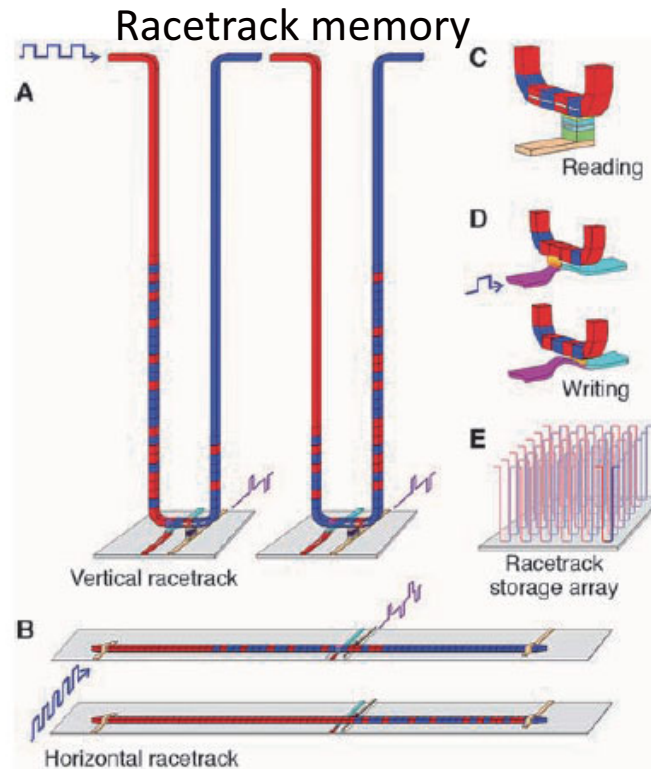


Spatial resolution: max. $\sim 15 \text{ nm}$

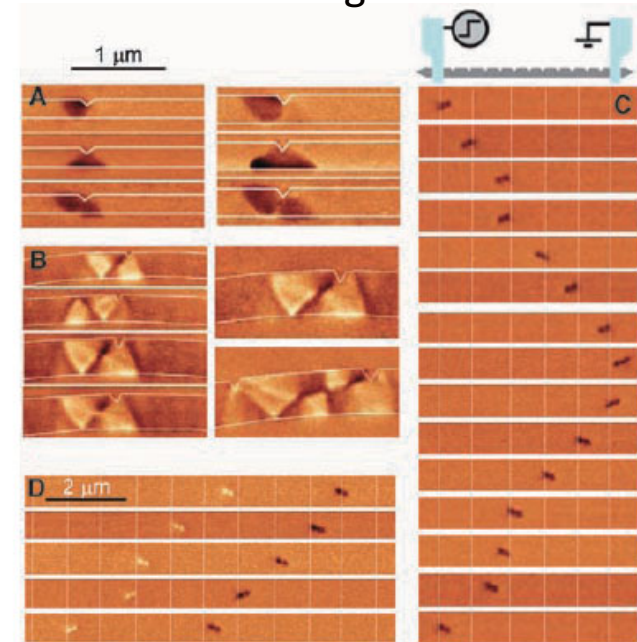
Temporal resolution: max. $\sim 70 \text{ ps}$

Racetrack memory: Magnetic thin films in Spintronics

Stuart Parkin, *et al.* (IBM Almaden)



MFM images



Domain wall velocity ~ 100 m/s (100 nm/ns)

まさに動いているところが見えるのでは

S.S.P. Parkin, *et al.*, Science **320**, 190 (2008)

DW displacement

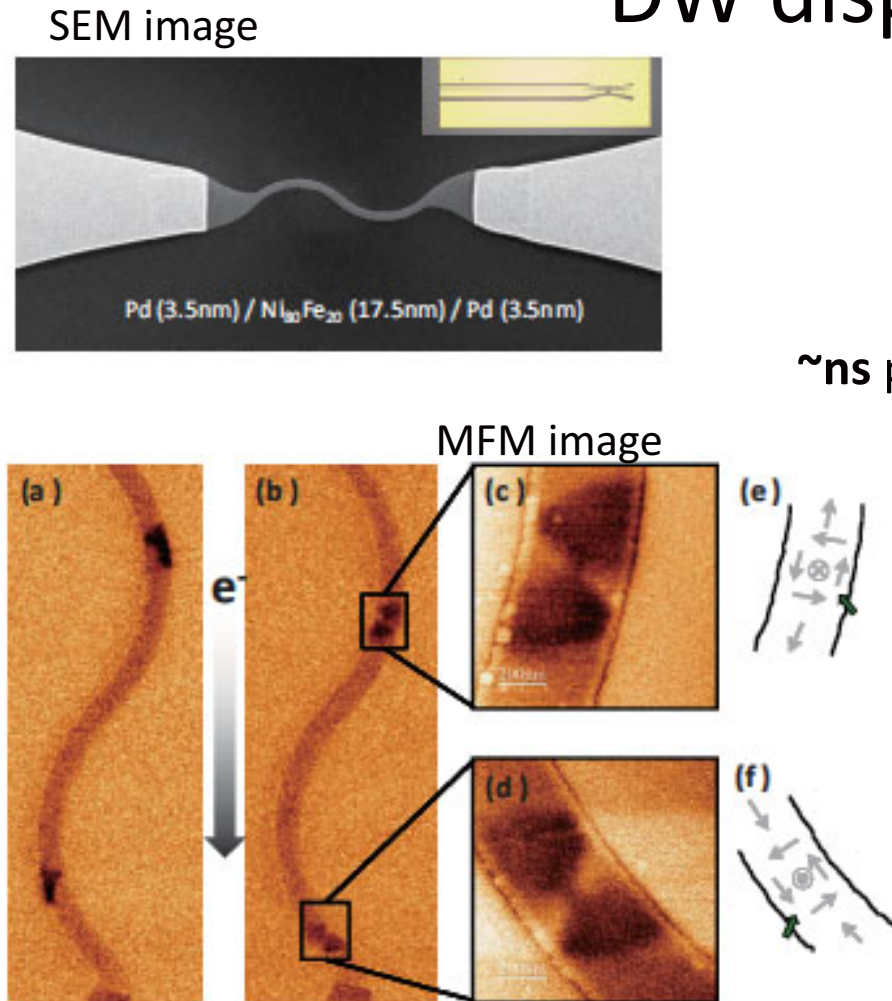


FIG. 3. (Color online) (a) MFM image of the initial magnetic state of the entire S-shaped nanostrip showing two ATWs. (b) Final magnetic state with two VWs displaced by 1.5 and 1.7 μm after transforming under a 1 ns current pulse of 3.6 TA/m^2 amplitude. [(c) and (d)] Zoom on the VWs, with schematics shown in (e) and (f), the bigger arrows indicating the vortex injection path.

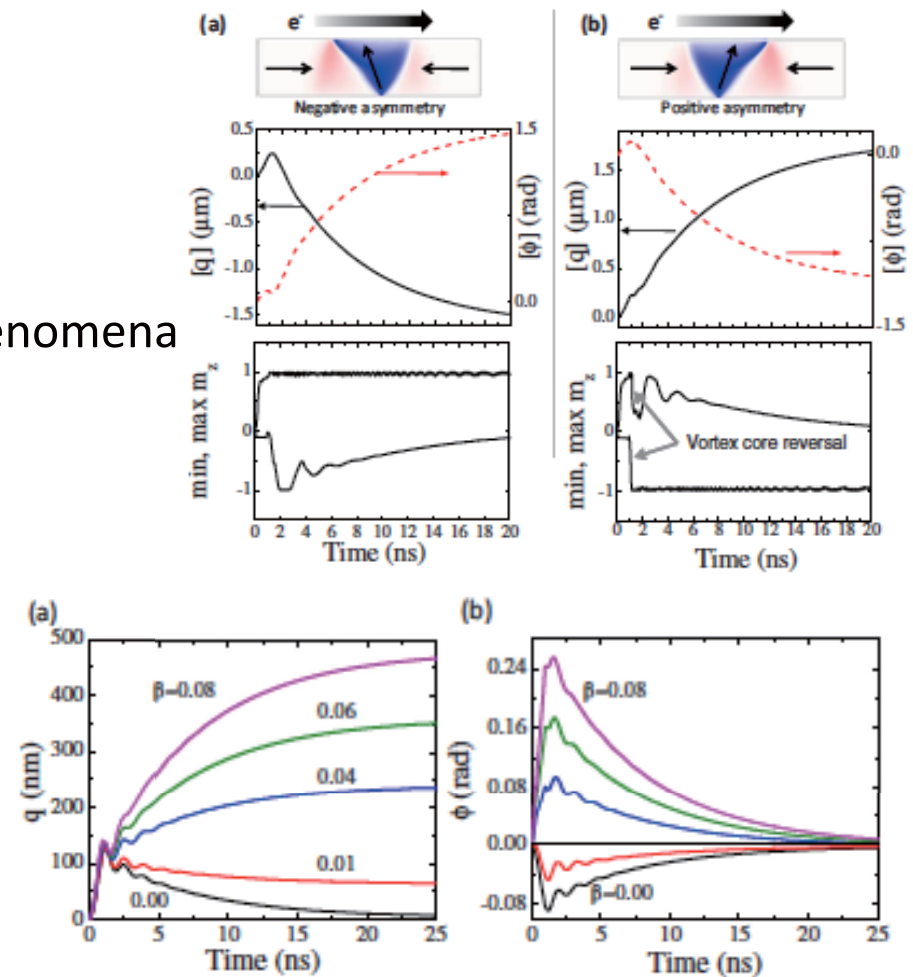


FIG. 8. (Color online) Micromagnetic simulations for a VW under a pulsed current of 1 ns and 3.8 TA/m^2 amplitude ($u = 133 \text{ m/s}$) for different values of β ($\alpha = 0.02$). The graphs show (a) the wall position q and (b) the generalized wall angle Φ .

ここからちょっと提案

- Soft x-ray + Hard x-ray

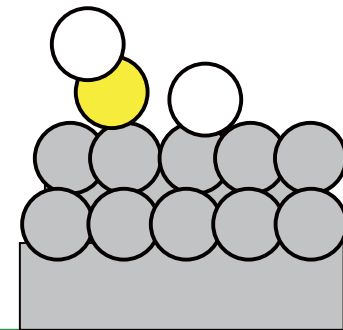
Soft x-ray + Hard x-ray

両方使えるビームラインがあったら何か面白いことができないか？

軽元素と重金属元素 – 同時(双方)測定実験

ex) CO酸化反応 on Pt 触媒

有機物のNEXAFS, XPSと貴金属触媒のEXAFS

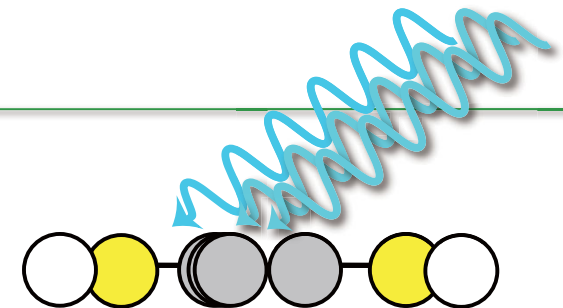


軟X線ポンプ – 硬X線プローブ実験

ex) 有機金属錯体

軟X線で励起・イオン化

引き続き構造変化を中心金属のXAFSで追跡する



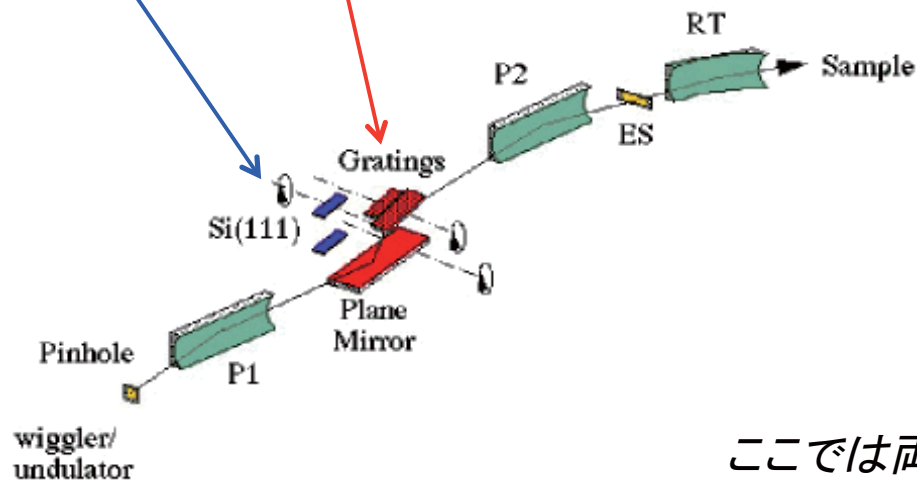
BL 7.2, Elettra

The parallel light beam impinges on the energy dispersing device which can be selected to be

a plane mirror - plane grating for the low energy range (120-2000 eV)

or

Si channel cut for the high energy range (2800 to 8000 eV).

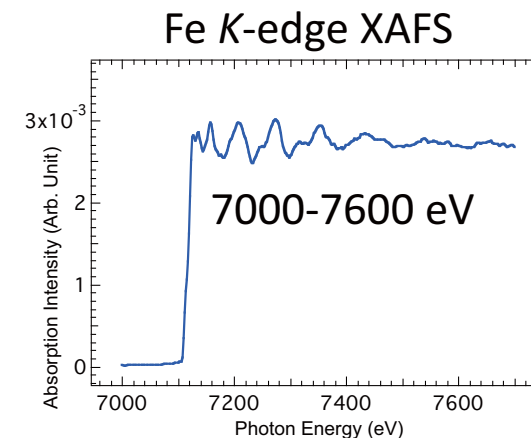
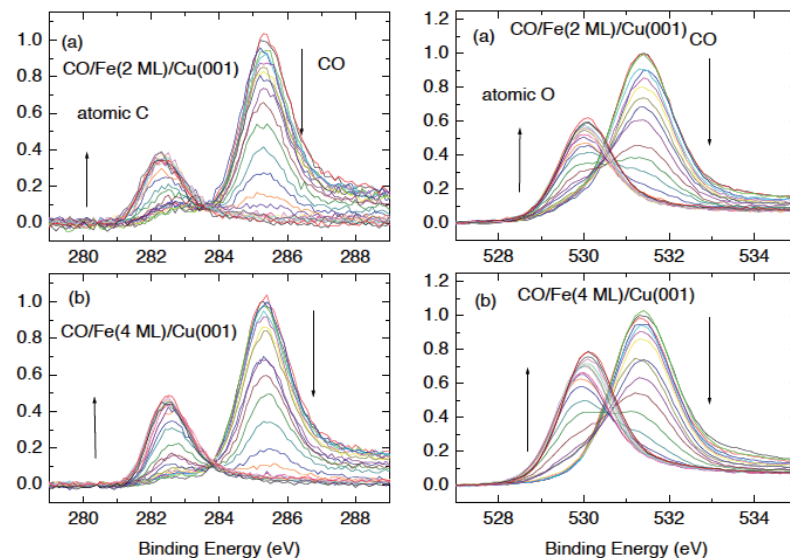
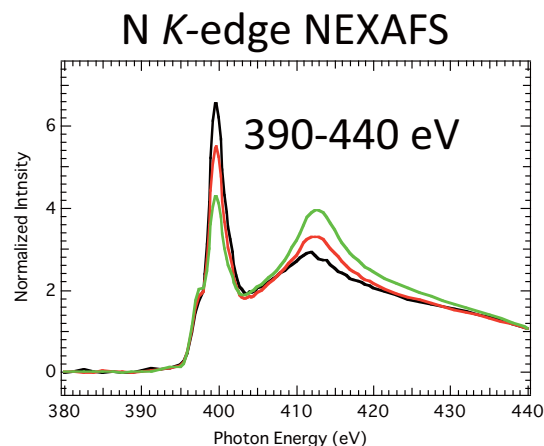


ここでは両方は使えるけど、同時には使えない

<http://www.elettra.trieste.it/experiments/beamlines/aloisa/index.html>

Soft & Hard x-rays to observe chemical reactions

C, O 1s XPS
280-290, ~530 eV



cf. Pt L_1 ; 11.6 keV

反応種(有機物)のNEXAFS, XPS: 250-600 eV
触媒金属のEXAFS (XANESも): 数 keV以上

Soft & Hard x-rays 両方使えたら

反応種を分光法で直接観察しつつ、
触媒金属の構造、電子状態を直接観察できる

The CO + NO Reaction over Pd: A Combined Study Using Single-Crystal, Planar-Model-Supported, and High-Surface-Area Pd/Al₂O₃ Catalysts

D. R. Rainer, S. M. Vesecky, M. Koranne, W. S. Oh, and D. W. Goodman

Department of Chemistry, Texas A&M University, College Station, Texas 77843-3255

Received September 4, 1996; revised December 12, 1996; accepted December 13, 1996

JOURNAL OF CATALYSIS 167, 234–241 (1997)

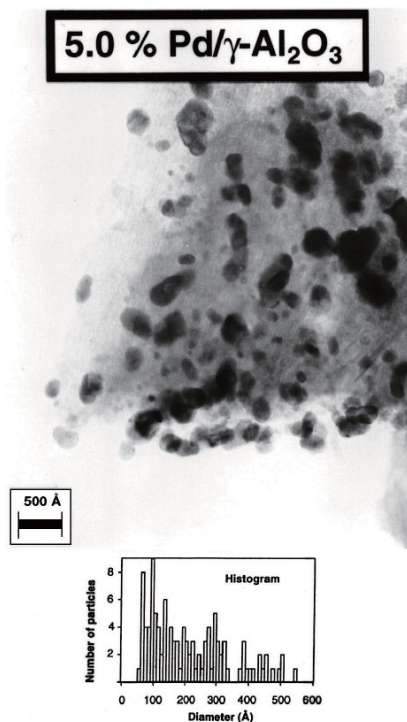


FIG. 2. TEM image and particle size histogram for a 5% Pd/ γ -Al₂O₃ powder catalyst prepared by incipient wetness impregnation.

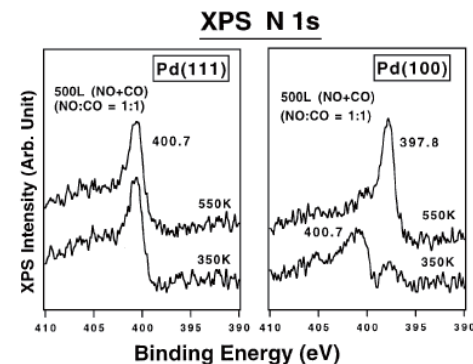
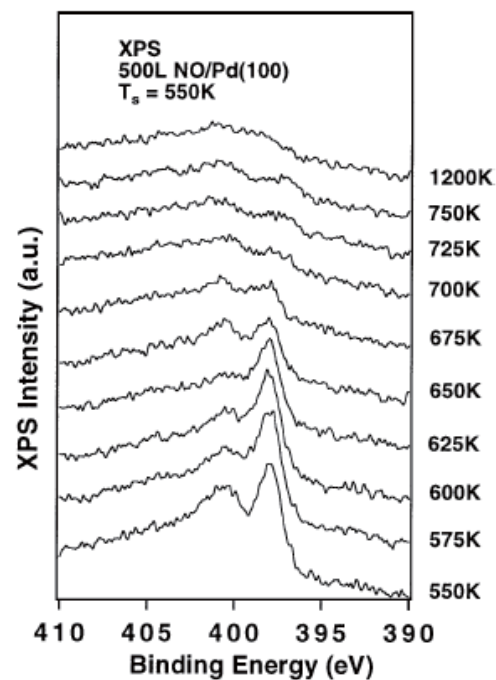


FIG. 7. XPS of the N1s peak on Pd(111) and (100) after a 500-langmuir exposure to CO+NO (1:1) at 350 K and 550 K.

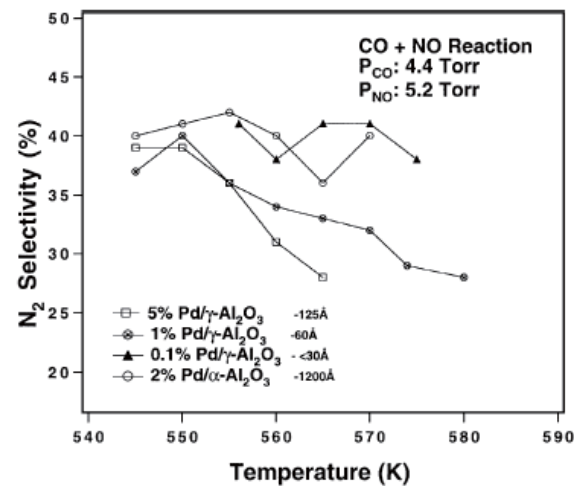


FIG. 11. N₂ selectivity vs temperature for the CO + NO reaction over each powder catalyst.

Effect of Oxygen Adsorption on the Chiral Pt{531} Surface

G. Held,^{*,†} L. B. Jones,^{‡,§} E. A. Seddon,[§] and D. A. King[†]

*Department of Chemistry, University of Cambridge, Lensfield Road, Cambridge CB2 1EW, U.K.,
Department of Chemistry, Surface Science Centre, University of Liverpool, Liverpool, U.K., and
CCLRC Daresbury Laboratory, Warrington, U.K.*

Received: October 29, 2004; In Final Form: February 8, 2005

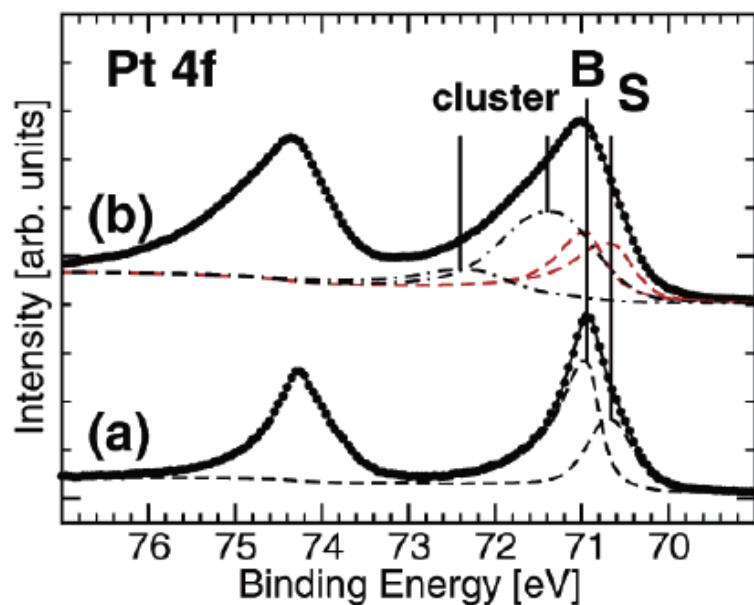


Figure 2. Pt 4f signal for (a) the clean Pt{531} surface and (b) the surface covered with oxide clusters. Filled circles represent the data points, fitted curves are shown as dashed (single peaks) and solid lines (sum of all peaks). For clarity only the peaks fitted to the Pt 4f_{7/2} line are shown. ($h\nu = 162$ eV (a), 650 eV (b); normal emission).

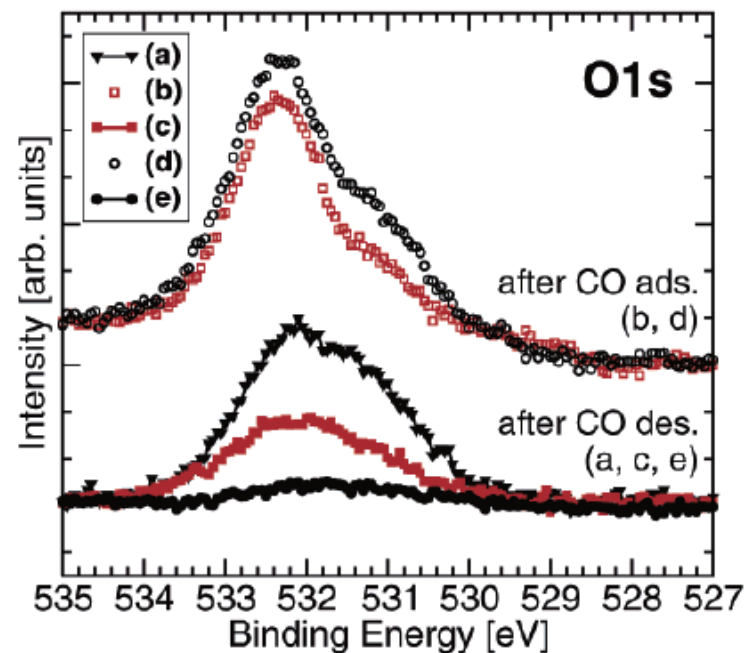


Figure 3. O 1s spectra (a) after oxygen treatment of the Pt{531} surface, (b) after first CO adsorption (45 L at 315 K), (c) after CO desorption (anneal to 620 K), (d) after second CO adsorption (45 L at 315 K), and (e) after second CO desorption (anneal to 620 K). See text for details. ($h\nu = 650$ eV; normal emission).

Summary

ERLでの表面反応、磁性薄膜の時間分解実験

- Laserをトリガーとして
 - 電子温度とカップルする分子の挙動のPump-Probe時間分解測定
 - 昇温で反応開始する表面反応のReal time時間分解測定
 - 分子再吸着による表面反応の時間分解測定
 - 分子脱離、再吸着による磁性薄膜のSRT過程の時間分解測定
- パルス磁場、電流をトリガーとする磁化反転過程の観測
 - 透過型軟X線顕微鏡
 - 磁気小角散乱
- ERLでのちょっとした新展開の可能性提案
 - 軟X線と硬X線が同時に使えるBL